Customer No. 22,852 Application No. 10/067,890 Attorney Docket No. 04208.0136-00000

AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions and listings of claims in the application:

1. (Currently Amended) A method for forming a recognition mark on a substrate for a bare chip carrier of a KGD, said substrate having a front surface and a back surface wherein wiring patterns are formed on a surface of one side of an insulating substrate, comprising the steps of:

forming wiring patterns on the front surface;

forming a conductive pattern as a recognition mark on the front surface onesurface where said wiring patterns are formed; and

forming a through hole from a the back surface where said wiring pattern is notformed toward said conductive pattern.

- 2. (Currently Amended) A method for forming a recognition mark on a substrate for a bare chip carrier of a KGD as claimed in claim 1, wherein said substrate is formed with a bump to be connected to said KGD on the surface where said wiring pattern is not formed on the back surface.
- 3. (Currently Amended) A method for forming a recognition mark on a substrate for a bare chip carrier of a KGD as claimed in claim 1, wherein said conductive pattern has a particular shape as said recognition mark.

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- 4. (Currently Amended) A method for forming a recognition mark on a substrate for a bare chip carrier of a KGD as claimed in claim 1, wherein a shape of said through hole defines said recognition mark.
- 5. (Currently Amended) A method for forming a recognition mark on a substrate for a bare chip carrier of a KGD as claimed in claim 4, wherein said through hole is filled with a plating material until the end of said plating lies in flush with said surface where said wiring pattern is not formed.
- 6. (Currently Amended) A method for forming a recognition mark on a substrate for a bare carrier of a KGD, wherein wiring patterns are formed on both surfaces of an insulating substrate said substrate having a front surface and a back surface, comprising the steps of:

forming wiring patterns on the front surface and the back surface;

forming a conductive pattern as a recognition mark on the front surface where said wiring patterns are formed; and

forming a through hole from a <u>the back</u> surface, where said KGD is not mounted and said wiring pattern is formed, toward said conductive pattern.

7. (Currently Amended) A method for forming a recognition mark on a substrate for a bare carrier of a KGD, said substrate having a plurality of layers and said plurality of layers including a back surface wherein wiring patterns are formed on a plurality of layers of an insulating substrate, comprising the steps of:

forming wiring patterns on one or more of the layers;

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forming a conductive pattern as a recognition mark on any layer where said wiring patterns are formed; and

forming a through hole from the back surface a surface of the substrate where said KGD is to be mounted toward said conductive pattern;

wherein forming the conductive pattern is performed at the same time as forming the wiring patterns.

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